



**DAG-003-0498002**

Seat No. \_\_\_\_\_

**B. Sc. / M. Sc. (Applied Physics) (Sem. VIII)  
(CBCS) Examination**

**April - 2022**

**Nanomaterials - I : Paper - VI  
(Synthesis & Types) (Core - VI) (New Course)**

**Faculty Code : 003**

**Subject Code : 0498002**

Time :  $2\frac{1}{2}$  Hours]

[Total Marks : 70

**Instructions :** (1) All questions are compulsory.  
(2) Numbers in the right margin indicate marks.

- 1** Write answer of short questions (Two marks each) **14**
- (1) What is Sol-Gel method?
  - (2) Give the name of precursors used in synthesis of metal and metal oxide nanoparticles.
  - (3) Define 0-D and 2-D.
  - (4) Draw the diagrams for three basic nucleation modes in film growth.
  - (5) What is meant by homo-epitaxial and hetero-epitaxial film growth?
  - (6) Define quantum confinement.
  - (7) Draw the schematic diagram illustrating the homogeneous nucleation and subsequent growth.
  - (8) Define nanoscience and nanotechnology.
  - (9) Write the application of CNT.
  - (10) What are advantages of self assembled monolayer (SAM)?
- 2** Write the detailed answers of following any two questions : **14**
- (1) Write short note on RF-DC sputtering.
  - (2) Describe the types of CVD.
  - (3) Describe various advanced nano ceramics and their applications.
  - (4) Describe various nanomaterials for consumer applications.

- 3** Write the detailed answers of following any two questions : **14**
- (1) Describe the synthesis of metal nanoparticles with suitable example and chemical reactions.
  - (2) Write the synthesis of  $\text{TiO}_2$  nanoparticles using Aerosol synthesis method.
  - (3) What is kinetically confined in synthesis of Nanoparticles, how can we achieve using micro emulsion method.
- 4** Write the detailed answers of following any two questions : **14**
- (1) Define semiconductor nanoparticles. Describe the synthesis of semiconductor nanoparticles.
  - (2) Explain the vapour liquid solid growth of Si nanowire using Au catalyst.
  - (3) Describe the synthesis of  $\text{SiO}_2$  nanoparticles using sol-gel method.
- 5** Write the detailed answers of following any two questions : **14**
- (1) Describe the Sol-gel processing of nanostructured film with suitable example.
  - (2) Describe various lithography techniques for growth of 1-D nanostructures.
  - (3) Write short note on electrospinning.
  - (4) Explain the ALD with neat diagram.
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